

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE



16/wm.
2/23/01

In re application of

Hiroshi TAKANASHI et al.

Docket No. 01497/FP/TOK-16-US/YH

Serial No. 09/262,077

Group Art Unit 1752

Filed March 4, 1999

Examiner S. Lee

NEGATIVE-WORKING PHOTOSENSITIVE
RESIN COMPOSITION AND PHOTOSENSITIVE
RESIN PLATE USING THE SAME

THE COMMISSIONER IS AUTHORIZED
TO CHARGE ANY DEFICIENCY IN THE
FEES FOR THIS PAPER TO DEPOSIT
ACCOUNT NO. 23-0975

PETITION FOR EXTENSION OF TIME

Assistant Commissioner for Patents
Washington, DC 20231

Sir:

Petition hereby is made for a two month extension of time to respond to the communication of September 20, 2000.

The fee of \$390.00 is

- (X) submitted herewith.
() to be charged to Deposit Account No. 23-0975. A duplicate copy of this Petition is enclosed.
() Small entity status of this application is established by the verified statement under 37 CFR 1.9 and 1.27 which
() is enclosed.
() has been previously submitted.

Respectfully submitted,

Hiroshi TAKANASHI et al.

By Matthew Jacob
Matthew Jacob
Registration No. 25,154
Attorney for Applicants

02/21/2001 HU10N61 00000013 09262077

02 FC:116

390.00 0P

MJ/pjm
Washington, D.C.
Telephone (202) 721-8200
February 20, 2001

RECEIVED
FEB 22 2001
TECHNOLOGY CENTER 1700